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(54) Title: SCALABLE, PRINTABLE, PATTERNED SHEET OF HIGH MOBILITY GRAPHENE ON FLEXIBLE SUBSTRATES

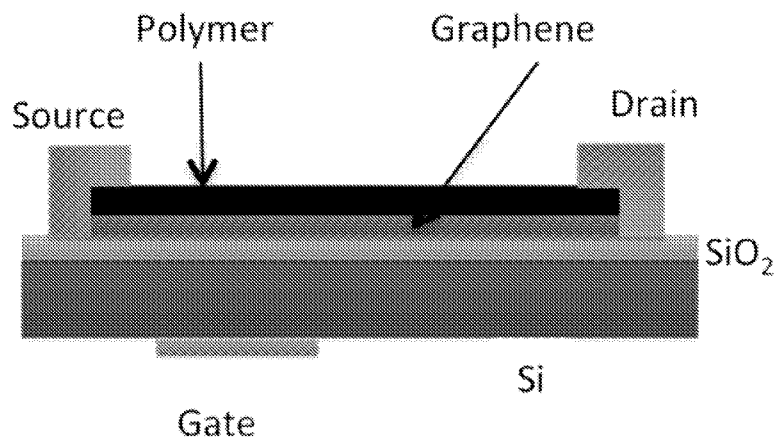


Figure 5(a)

(57) Abstract: The present invention provides methods for fabricating graphene workpieces. The present invention also provides for products produced by the methods of the present invention and for apparatuses used to perform the methods of the present invention.



SCALABLE, PRINTABLE, PATTERNED SHEET OF HIGH MOBILITY GRAPHENE ON FLEXIBLE SUBSTRATES

CROSS REFERENCE TO RELATED APPLICATIONS

[0001] This application claims benefit of U.S. Patent Application No. 61/983,014, filed April 23, 2014, the disclosure of which is incorporated herein by reference in its entirety.

GOVERNMENT RIGHTS

[0002] The subject matter disclosed herein was made with government support under award/contract/grant number DMR08-32802 awarded by the Nano/Bio Interface Center NSF NSEC. The Government has certain rights in the herein disclosed subject matter.

FIELD OF THE INVENTION

[0003] The disclosed invention is directed toward the fields of graphene workpieces and of manufacturing methods thereof.

BACKGROUND

[0004] The present application generally relates to methods and apparatus for transfer of films from one or more substrates to another, where the film to be transferred is patterned during the transfer step.

[0005] Since the first isolation of graphene in 2004, interest in the material has surged in the research community and more recently in industry as the first commercial ventures in graphene production and applications have emerged. Graphene is a single atom thick sheet of carbon atoms packed in a honeycomb lattice that has unique properties owing to its two-dimensional geometry and aromatic chemical structure. The unique band structure of this material shows a linear dispersion relation at low energies, allowing the holes and electrons to have zero effective mass and behave like relativistic particles. This leads to impressive electrical properties, such as measured mobilities of 200,000 cm²/V-s and ballistic transport on the micrometer scale at room temperature. Additionally, the superior tensile strength of the material allows for high electrical performance even under bending and deformation. Due to these fantastic properties, there has been great interest for applications in high performance nanoelectronics, flexible electronics, and environmental/biological monitoring applications.

[0006] Graphene can be grown in high quality sheets on catalytic metal by chemical vapor deposition at industrial scale, presenting an opportunity for graphene commercialization that is being pursued by multiple companies. In conventional approaches, graphene is coated

with a thin polymer layer (e.g., polymethylmethacrylate - PMMA) to provide mechanical stability and then removed from a copper growth substrate for transfer onto another substrate as a full sheet that may then be patterned into electrical devices, etc. There are several disadvantages of this – e.g., the graphene can be wrinkled during the transfer process since the PMMA layer is very thin and flexible; the graphene can be contaminated with PMMA residue after cleaning; and the subsequent patterning process can expose the graphene to chemical contamination. Each of these causes the physical properties (including the carrier mobility) of the graphene to degrade. Processes are needed for transferring graphene from growth substrates to other surfaces while protecting the beneficial properties of the material so that it may be used in commercial devices.

[0007] Thus, there is a need for processes that enable transfer of graphene from growth substrates to other surfaces. There are sets of materials “beyond graphene” (e.g., few-layer graphene, boron nitride, molybdenum disulfide, other transition metal dichalcogenides, and the like) with similar needs for advanced methods of film transfer. The instant disclosure is directed to these and other important needs.

SUMMARY

[0008] The present disclosure provides methods for forming a workpiece, the methods comprising growing pristine monolayer continuous graphene on a catalytic film to form a graphene/catalytic film bilayer, attaching a first layer of material on top of the graphene surface, and releasing the graphene from the catalytic film, such that the first layer of material is sufficiently rigid that it resists folding or tearing through the rest of the process. In this way the process ensures that the graphene film preserves its very high electronic and structural quality. In addition, there are sets of materials “beyond graphene” (e.g., few-layer graphene, boron nitride, molybdenum disulfide, other transition metal dichalcogenides, and the like) with similar needs for advanced methods of film transfer. The disclosure is directed to these and other important needs.

[0009] The present disclosure also provides workpieces, comprising a substrate, a patterned layer of graphene disposed on the substrate, and a patterned layer of material disposed on the graphene. The present disclosure also provides electronic devices comprising the workpieces.

[0010] The present disclosure also provides workpieces, comprising a substrate, a layer of pristine monolayer continuous graphene disposed on the substrate, and a patterned layer of material disposed on the graphene.

[0011] The present disclosure also provides workpieces, comprising a patterned layer of graphene and a patterned layer of a first material disposed on the graphene.

[0012] The general description and the following detailed description are exemplary and explanatory only and are not restrictive of the invention, as defined in the appended claims. Other aspects of the present disclosure will be apparent to those skilled in the art in view of the detailed description of the invention as provided herein.

BRIEF DESCRIPTION OF THE DRAWINGS

[0013] The summary, as well as the following detailed description, is further understood when read in conjunction with the appended drawings. For the purpose of illustrating the invention, there are shown in the drawings exemplary embodiments of the invention; however, the invention is not limited to the specific methods, compositions, and devices disclosed. In addition, the drawings are not necessarily drawn to scale. In the drawings:

[0014] **FIG 1** illustrates an embodiment of the present invention directed to a workpiece. The workpiece in the upper left has a graphene top layer and a copper bottom layer. The middle left workpiece is the same as the top left workpiece except it has a polymer layer on top.

[0015] **FIG 2** illustrates an alternative embodiment of the present invention directed to workpieces on various solid and flexible substrates.

[0016] **FIG 3** illustrates exemplary embodiments of the present invention directed to workpieces.

[0017] **FIG 4** illustrates an exemplary embodiment of the present invention directed to workpieces.

[0018] **FIG 5(a)** illustrates an exemplary embodiment of the present invention directed to an electronic device comprising a workpiece.

[0019] **FIG 5(b)** provides electronic test data of an embodiment of the present invention directed to an electronic device comprising a workpiece.

[0020] **FIG 6** provides a process whereby an embodiment is directed to an electronic device comprising a workpiece that is applied to a target substrate. In this figure, the workpiece in the upper left has a top layer of graphene monolayer and a bottom layer of copper. The middle workpiece on the left has a top layer of polymer a middle layer of graphene monolayer and a bottom layer of copper. The bottom left workpiece has a top layer of copper, a second layer of graphene monolayer, a third layer of polymer and a bottom layer that is the target

substrate. The workpiece on the right has the target substrate on the bottom, polymer as the middle layer and graphene monolayer as the top layer.

DETAILED DESCRIPTION OF ILLUSTRATIVE EMBODIMENTS

[0021] The present invention may be understood more readily by reference to the following detailed description taken in connection with the accompanying figures and examples, which form a part of this disclosure. It is to be understood that this invention is not limited to the specific devices, methods, applications, conditions or parameters described and/or shown herein, and that the terminology used herein is for the purpose of describing particular embodiments by way of example only and is not intended to be limiting of the claimed invention. Also, as used in the specification including the appended claims, the singular forms “a,” “an,” and “the” include the plural, and reference to a particular numerical value includes at least that particular value, unless the context clearly dictates otherwise. The term “plurality”, as used herein, means more than one. When a range of values is expressed, another embodiment includes from the one particular value and/or to the other particular value. Similarly, when values are expressed as approximations, by use of the antecedent “about,” it will be understood that the particular value forms another embodiment. All ranges are inclusive and combinable.

[0022] It is to be appreciated that certain features of the invention which are, for clarity, described herein in the context of separate embodiments, may also be provided in combination in a single embodiment. Conversely, various features of the invention that are, for brevity, described in the context of a single embodiment, may also be provided separately or in any subcombination. Further, reference to values stated in ranges include each and every value within that range.

[0023] In one embodiment, the disclosure provides scalable printing-based method for patterning monolayer graphene into arbitrary geometries on flexible polymer substrates while maintaining the high intrinsic mobility of the material ($\sim 10,000 \text{ cm}^2/\text{V}\cdot\text{s}$). In one embodiment of the invention, a graphene-on-polymer material can be made via a process comprising laser printing to pattern printer toner onto graphene grown via chemical vapor deposition on a copper foil substrate to achieve wrinkle-free release from the growth substrate. The graphene layer of the resulting graphene-on-polymer structure retains the high mobility and environmental sensitivity characteristic of high-quality graphene, making the structure suitable for use in a number of applications in flexible/foldable electronics, wearable vapor sensors for environmental monitoring, printable biosensors for facile medical diagnosis, as well as inexpensive next-generation energy materials (supercapacitors, transparent electrodes).

[0024] In one embodiment, the present invention provides methods of forming a workpiece. These methods may include growing graphene (e.g., pristine monolayer continuous graphene) on a catalytic film to form a graphene/catalytic film bilayer. The methods may also include disposing a first layer of material on top of the graphene surface and releasing the graphene from the catalytic film. In some embodiments, growing graphene on a catalytic film is performed by chemical vapor deposition (CVD) at either atmospheric or low pressure. The catalytic film can comprise Cu or Pt foil in some embodiments; catalytic materials that can support graphene growth will be known to those of ordinary skill in the art. In some embodiments, the catalytic foil can comprise a roll and the graphene growing can occur in a “roll-to-roll” system, which may incorporate a CVD process.

[0025] The first layer of material on top of the graphene can be disposed as a patterned or unpatterned layer; in some embodiments it is formed with a printing process that allows for patterning, e.g., printing on the surface of the graphene surface with a laser printer, by printing on the surface of the graphene surface with an inkjet printer with a polymer ink, by selective sintering of material (selective heat sintering, selective laser sintering, or both) in a 3D printer, or by selectively depositing a liquid binding material in a powder-bed layer of a 3D printer. Other printing methods may be used as will be known to those of ordinary skill in the art. The printing process should be engineered so as to avoid damaging or destroying the graphene, which may occur, for example, through the use of a sintering process that exposes the graphene to excessively high temperatures in the presence of oxygen. Preferably (though not necessarily), the first layer of material is disposed and patterned if so desired without the use of a photoresist material as these materials can damage the electronic characteristics of the graphene. The first layer of material must be made solid and must bond to the graphene in order to provide structural support to the released graphene. Any printing process which is capable of disposing a first layer of any material capable of solidifying and bonding to the graphene is suitable. In some embodiments, a second layer of material can be disposed on top of the first layer of material. In preferred methods, the second layer of material is a substantially unpatterned layer that does not substantially contact the graphene. The releasing of the graphene from the catalytic film can be performed by a bubbling transfer process, as described by Gao et al., “Repeated growth and bubbling transfer of graphene with millimetre-size single-crystal grains using platinum,” *Nature Communications* 3(2012):699, incorporated herein by reference in its entirety for all purposes. In methods utilizing a second layer of material that does not substantially contact the graphene, the bubbling transfer process results in the removal of all graphene which is not in contact with the first layer of material. In some embodiments the method further comprises attaching the released

graphene to a substrate, which can comprise one or more of the following: glass, silicon, silicon dioxide, aluminum oxide, sapphire, germanium, gallium arsenide, indium phosphide, an alloy of silicon and germanium, PET, polyimide, other plastics, or silk. In one preferred embodiment, the substrate comprises Si/SiO₂ and the graphene is attached to the SiO₂ surface of the substrate.

[0026] The present disclosure also provides workpieces. These workpieces may include a substrate, a patterned layer of graphene disposed on the substrate, and a patterned layer of a first material disposed on the graphene. In some embodiments, a workpiece further comprises an unpatterned layer of a second material disposed on the patterned layer of a first material, wherein the unpatterned layer of material does not substantially contact the layer of graphene or the substrate. The substrate may comprise one or more of the following: glass, silicon, silicon dioxide, aluminum oxide, sapphire, germanium, gallium arsenide, indium phosphide, an alloy of silicon and germanium, and the like. The workpieces preferably comprise graphene with a carrier mobility of greater than about 5,500 cm²/V-s. In preferred embodiments, the patterned layer of a first material disposed on the graphene comprises a thickness of less than about 20 micrometers, less than about 10 micrometers, or even less than about 5 micrometers. Also further preferred are embodiments wherein the patterned layer of a first material disposed on the graphene, the unpatterned layer of a second material disposed on the patterned layer of material, or each individually comprises a thickness of less than about 10 micrometers. In some embodiments the workpieces can comprise a patterned layer of a first material disposed on the graphene comprises features having a characteristic dimension of less than about 10 micrometers.

[0027] The present invention also provides for electronic devices comprising the workpieces described herein. Such an electronic device can may include a workpiece integrated on semiconductor substrates along with electrode contacts.

[0028] The present invention also provides alternative workpieces. Such workpieces suitably include a substrate, a layer of graphene (e.g., pristine monolayer continuous graphene) disposed on the substrate, and a patterned layer of a first material disposed on the graphene. The substrate can comprise a catalytic film that can support graphene growth, which comprises Cu or Pt foil in some embodiments; catalytic materials that can support graphene growth will be known to those of ordinary skill in the art. In preferred embodiments, the first material can comprise a polymer or plastic material. In further preferred embodiments, the first material can comprise a flexible polymer. In preferred embodiments, the patterned layer of a first material disposed on the graphene comprises a thickness of less than about 20 micrometers, less than about 10 micrometers, or even less than about 5 micrometers.

[0029] In other embodiments, the present invention provides workpieces, comprising a patterned layer of graphene, and a patterned layer of a first material disposed on the graphene. In some embodiments, the workpieces further comprise an unpatterned layer of a second material disposed on the patterned layer of a first material, wherein the unpatterned layer of a second material does not substantially contact the layer of graphene. Preferably, the first material, the second material, or both comprises a flexible polymer. Suitable flexible polymers include commercial printer toners, polymer inks, or materials which are flexible following disposition via 3-D printing. The patterned layer of a first material disposed on the graphene, the unpatterned layer of a second material disposed on the patterned layer of material, or each individually may comprise a thickness of less than about 20 micrometers, less than about 10 micrometers, or even less than about 5 micrometers.

[0030] The disclosure is illustrated by the following non-limiting examples.

EXAMPLE 1

[0031] In one aspect, the present disclosure provides a methods that result in pristine graphene layers on a thin, flexible toner or polymer substrate in any desired pattern that can be defined by a printing process.

[0032] First, pristine monolayer continuous graphene is grown on a copper film by chemical vapor deposition (CVD) at either atmospheric or low pressure to create a copper film/graphene bi-layer. Next, the copper film/graphene bi-layer is attached to a suitable support and inserted into a printing apparatus for the attachment of patterned material to the graphene surface. In one embodiment, the copper film/graphene bi-layer is attached to ordinary printer paper with tape and inserted into a laser printer. In other embodiments, the copper film/graphene bi-layer is attached to a suitable support for insertion into a 3D printer. In yet other embodiments, graphene can be formed on a roll of catalytic foil, such as in a “roll-to-roll” process, which can then be fed through a printing apparatus. Patterns can be printed successfully without damaging the graphene using a variety of printing apparatuses and techniques. These techniques result in a pattern of a solid polymer layer on the graphene surface. In one embodiment, a conventional laser printer can be used. Other printing methods include color laser printers and inkjet printing using polymer or polymer-composite inks. In further embodiments, a patterned layer of material may be formed on the surface of the graphene using a 3D printer, which printer may utilize selective heat sintering or selective laser sintering, or alternatively may utilize selective deposition of a liquid binding material in a powder-bed layer. The printing process should be engineered so as to avoid damaging or destroying the graphene, which may occur, for example,

through the use of a sintering process that exposes the graphene to excessively high temperatures. The printed layer's thickness is determined by the printing apparatus used, which can be about around 10 micrometers in the case of laser printer toner, although other thicknesses in the range of from about 500 nm to about 100 micrometers are also suitable; the thickness may be varied as desired for particular applications. This can be adjusted through engineering of the printing process. The line width of the patterning is determined by the resolution of the printer, which can be as small as 1 micrometer, 5 micrometers, or even 10 micrometers for the advanced laser printers, for example. No subsequent processing is needed. There is no need for the use of photoresist, as the subsequent "bubble method" release step leads to a patterned graphene layer attached to the thin layer of printed material.

[0033] A process for making a workpiece using a conventional laser printer is shown schematically in FIG. 1.

[0034] Next, graphene is transferred off of the copper film using suitable techniques. This can be achieved without applying any additional layers that provide mechanical backing for the graphene. In some embodiments, the "bubble transfer" method described by Gao et al., "Repeated growth and bubbling transfer of graphene with millimetre-size single-crystal grains using platinum," *Nature Communications* 3(2012):699, incorporated herein by reference in its entirety for all purposes. Other methods that do not apply additional layers that provide mechanical backing for the graphene are also suitable, e.g., dissolving the catalytic foil. The graphene that has the patterned layer of printed material disposed on it then transfers off the copper foil intact while unsupported graphene disintegrates during the process. Thus, the material that survives the transfer process is the patterned graphene-material complex that was created during the printing process.

[0035] The graphene-on-material structure can be removed from the transfer bath using tweezers, or a PET sheet, and cleaned with standard processes. The printed material acts as a rigid backbone and provides mechanical support to the underlying graphene layer. Workpieces fabricated using the method described herein, with a conventional laser printer, and then transferred to a set of solid and flexible substrates, are shown in FIG 2. Graphene was synthesized on copper catalytic foil to form a copper film/graphene bi-layer. The bi-layer was attached with transparent tape to a sheet of standard 8.5" x 11" paper, with the copper layer facing the paper and the graphene layer exposed. The paper, with bi-layer attached, was then inserted into a conventional laser printer and a pattern was printed with commercial black laser printer toner or color laser printer toner. The workpiece can be curled around an object, such as an object with a radius 0.5 mm as shown in FIG. 2. Following release from curling, there were

no visible signs of damage, and electrical properties of the graphene were measured before and after curling, indicating that the curling process did not degrade the electrical properties.

Multiple workpieces fabricated using the method described herein, with a conventional laser printer, are shown in FIG. 3, which includes patterned graphene-on-polymer workpieces placed onto a glass slide for storage and later use. Additional workpieces have been fabricated using the method described herein with a color laser printer using various colored printer toners, which yielded similar results.

EXAMPLE 2

[0036] In some embodiments, a 3D printer is used as in Example 1, with the further step of attaching a second layer of material on top of the patterned layer of material. As in Example 1, pristine monolayer continuous graphene is grown on a catalytic film by chemical vapor deposition (CVD) at either atmospheric or low pressure to create a catalytic film/graphene bi-layer. Next, the catalytic film/graphene bi-layer is attached to a suitable support and inserted into a 3D printing apparatus for the attachment of patterned material to the graphene surface. In the 3D printer, a patterned layer is disposed on the graphene surface of the catalytic film/graphene bi-layer.

[0037] After the formation of the patterned layer of material, a second, unpatterned layer can be formed on top of the patterned layer of material. This unpatterned layer may lie across the top of the patterned layer of material and unsintered or unbound 3D-printer build material that is disposed within the pattern. As a result, the unpatterned layer can be disposed on the first layer of patterned material without contacting the graphene. If the “bubble transfer” removal method is used, unsintered or otherwise unbound build material will be removed along with the disintegrating graphene that has no first layer disposed on it, leaving the patterned graphene matching the first patterned layer of material. In this fashion, the remaining graphene pattern is the same as one that would result from the process in Example 1, which did not utilize a second unpatterned layer of material. The second, unpatterned layer is useful for, inter alia, providing more structural support to the workpiece and allowing for the use of commercial wafer handling systems, such as vacuum, suction, or Bernoulli grippers.

EXAMPLE 3

[0038] Graphene-on-polymer samples fabricated as described in Example 1, with a conventional laser printer used to create the patterned layer of polymer on the graphene layer, were evaluated for electrical performance. Samples comprised of a pristine monolayer graphene

on a polymer toner backing. The samples were curled 360 degrees with a radius of curvature of less than 1 mm as shown in FIG 2 without affecting electrical performance, including carrier mobility.

[0039] Sample measurements were conducted using the sample geometry shown in FIG 5(a), in order to measure the current-gate voltage characteristic (I-V_g) of the graphene layer in a Graphene-on-polymer sample. The measurements are consistent with mobilities exceeding 5,000 cm²/V-s, similar to what is intrinsic to CVD-grown graphene. FIG. 5(b) shows a typical I-V_g of a sample after it has been curled around an object with a radius of 0.5 mm. Using a standard model, the inferred mobility is about 5,500 cm²/V-s. This value is substantially equivalent to that found for an identical sample that was not curled, implying that the graphene properties are unaltered by the curling process.

Terms

[0040] The terminology used herein is for the purpose of describing particular aspects only and is not intended to be limiting. For example, the term “comprising” can include the embodiments “consisting of” and “consisting essentially of.” Unless defined otherwise, all technical and scientific terms used herein have the same meaning as commonly understood by one of ordinary skill in the art to which this disclosure belongs. In this specification and in the claims which follow, reference will be made to a number of terms which shall be defined herein.

[0041] When ranges are used herein for physical properties or chemical properties, all combinations, and subcombinations of ranges for specific embodiments therein are intended to be included.

[0042] The disclosures of each patent, patent application, and publication cited or described in this document are hereby incorporated herein by reference, in its entirety.

[0043] Those skilled in the art will appreciate that numerous changes and modifications can be made to the preferred embodiments of the invention and that such changes and modifications can be made without departing from the spirit of the invention. It is, therefore, intended that the appended claims cover all such equivalent variations as fall within the true spirit and scope of the invention.

What is Claimed:

1. A method of forming a workpiece, the method comprising:
 - growing pristine monolayer or few-layer continuous graphene on a catalytic film to form a graphene/catalytic film bilayer;
 - disposing a first layer of material on top of the graphene surface in a predetermined pattern; and
 - releasing the graphene from the catalytic film so that the graphene is in the form of the patterned layer.
2. The method of claim 1, wherein the growing pristine monolayer continuous graphene on a catalytic film is performed by chemical vapor deposition at either atmospheric or low pressure.
3. The method of claim 1, wherein the disposing a first layer of material on top of the graphene surface is performed by printing on the surface of the graphene surface with a laser printer.
4. The method of claim 1, wherein the disposing a first layer of material on top of the graphene surface is performed by printing on the surface of the graphene surface with an inkjet printer with a polymer ink.
5. The method of claim 1, wherein the disposing a patterned first layer of material on top of the graphene surface is performed by screen printing, flexography, gravure, offset lithography, nanoimprint lithography, or any combination thereof.
6. The method of claim 1, wherein the disposing a first layer of material on top of the graphene surface is performed by selective sintering of material in a 3D printer.
7. The method of claim 6, wherein the selective sintering comprises one or more of selective heat sintering and selective laser sintering.
8. The method of claim 1, wherein the disposing a first layer of polymer on top of the graphene surface is performed by selectively depositing a liquid binding material in a powder-bed layer of a 3D printer.

9. The method of claim 1, wherein the catalytic film comprises Cu, Ni or Pt foil.
10. The method of claim 1, wherein the releasing the graphene from the catalytic film comprises a bubbling transfer process, mechanical separation process, or a combination thereof.
11. The method of claim 1, wherein the releasing the graphene from the catalytic substrate is performed by etching the catalytic substrate.
12. The method of any of claims 1, 3, 4, 5, 6, 7, or 8, further comprising disposing a second layer of material on top of the first layer of material on top of the graphene surface before releasing the graphene from the catalytic film.
13. The method of claim 12, wherein the second layer of material is substantially unpatterned.
14. The method of any of claims 1, 2, 3, 4, 5, 6, 7, 8, 9, 10, 11, 12, or 13, further comprising attaching the released graphene and patterned layer to a second substrate.
15. The method of claim 14, wherein the second substrate comprises one or more of glass, silicon, silicon dioxide, aluminum oxide, sapphire, germanium, gallium arsenide, indium phosphide, an alloy of silicon and germanium, PET, polyimide, other plastics, silk, or any combination thereof.
16. The method of claim 14, wherein the substrate comprises Si/SiO₂ and the graphene is attached to the SiO₂ surface of the substrate.
17. The method of claim 14 wherein the released graphene attaches to the second substrate and the patterned layer is attached to the graphene.
18. The method of claim 14 wherein the patterned layer attaches to the second substrate and the graphene layer is attached to the patterned layer.
19. The method of claim 14 wherein the second substrate is composed of one or more layers of patterned and unpatterned materials.

20. A workpiece, comprising:
 - a second substrate;
 - a patterned layer of graphene disposed on the second substrate; and
 - a patterned layer of a first material disposed on the graphene.
21. The workpiece of claim 17, further comprising an unpatterned layer of a second material disposed on the patterned layer of a first material, wherein the unpatterned layer of material does not substantially contact the layer of graphene or the second substrate.
22. The workpiece of claim 17, wherein the second substrate comprises one or more of the following: glass, silicon, silicon dioxide, aluminum oxide, sapphire, germanium, gallium arsenide, indium phosphide, an alloy of silicon and germanium, PET, polyimide, other plastics, silk, or any combination thereof.
23. The workpiece of claim 17, wherein the patterned layer of a first material disposed on the graphene has a thickness of less than 10 micrometers.
24. The workpiece of claim 18, wherein the patterned layer of a first material disposed on the graphene, the unpatterned layer of a second material disposed on the patterned layer of material, or both comprises a thickness of less than 10 micrometers.
25. The workpiece of claim 17, wherein the patterned layer of a first material disposed on the graphene comprises features having a characteristic dimension of less than 10 micrometers.
26. The workpiece of claim 20, further comprising an unpatterned layer of a second material disposed on the patterned layer of a first material, wherein the unpatterned layer of second material does not substantially contact the layer of graphene.
27. The workpiece of claim 26, wherein the second material comprises a flexible polymer.
28. The workpiece of claim 27, wherein the first material, the second material, or both comprises a flexible polymer.

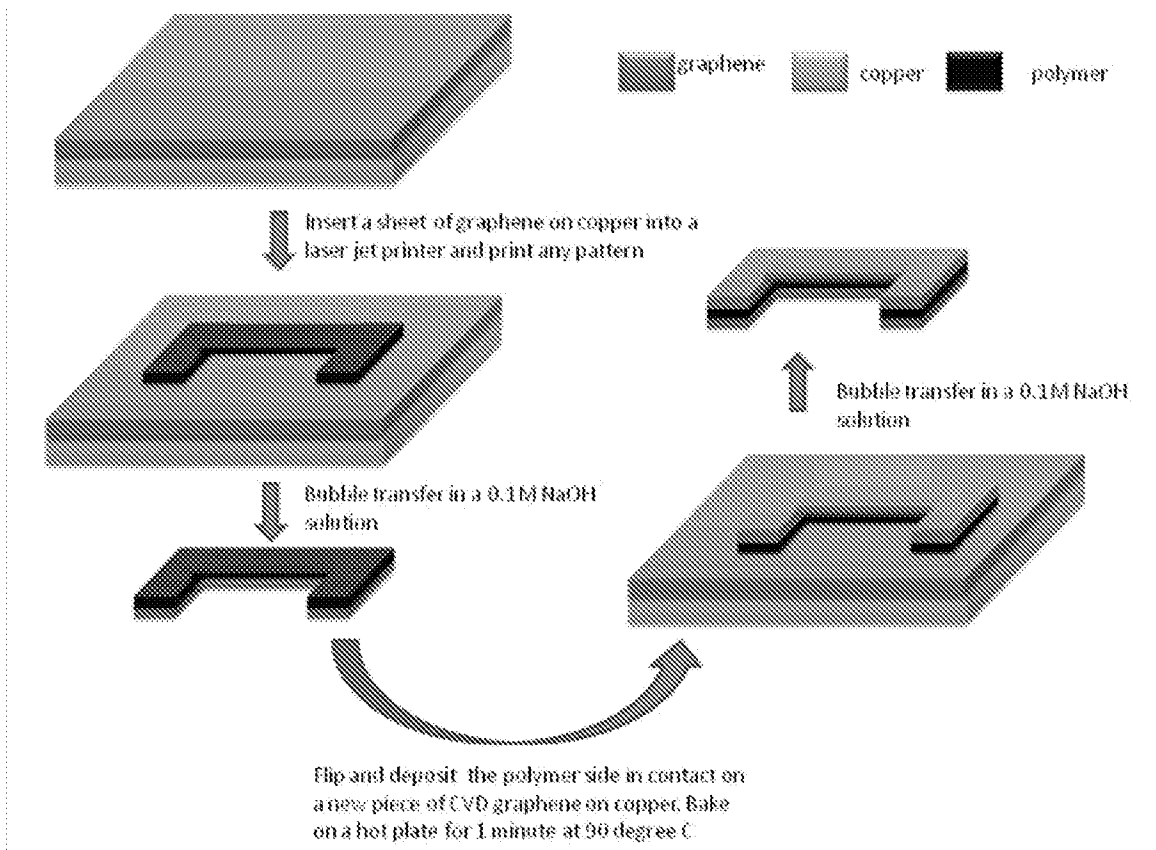


FIG. 1

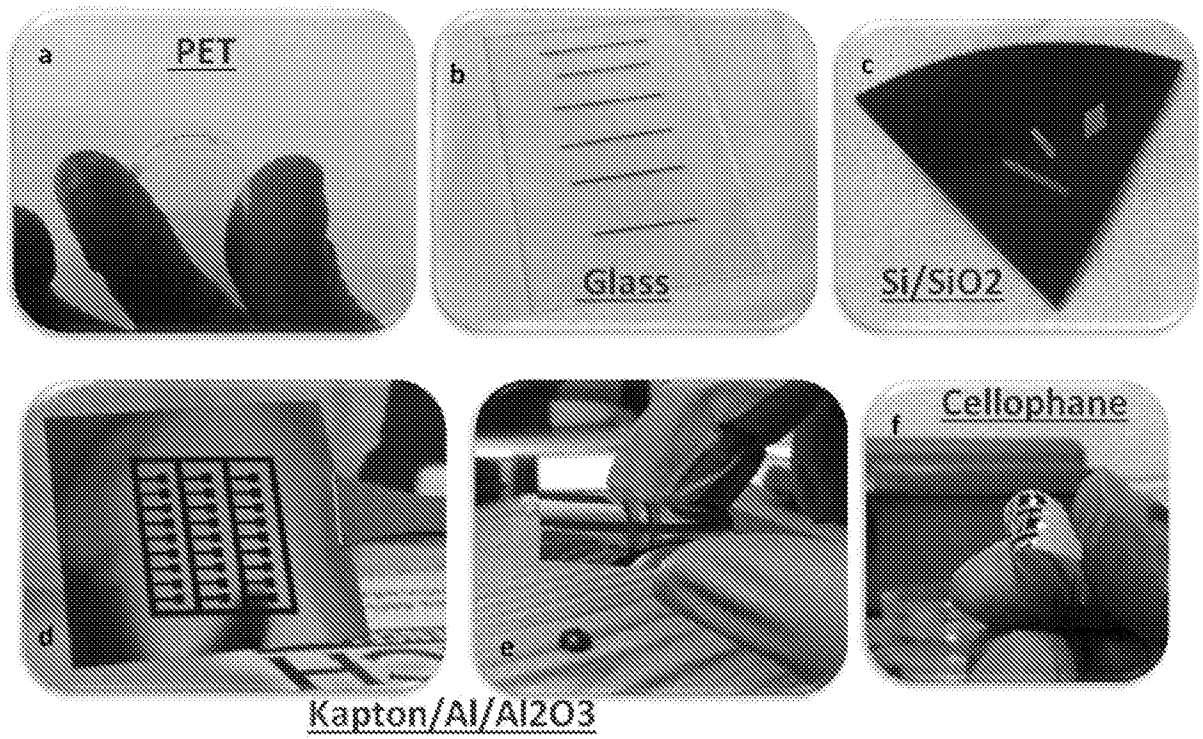


FIG. 2

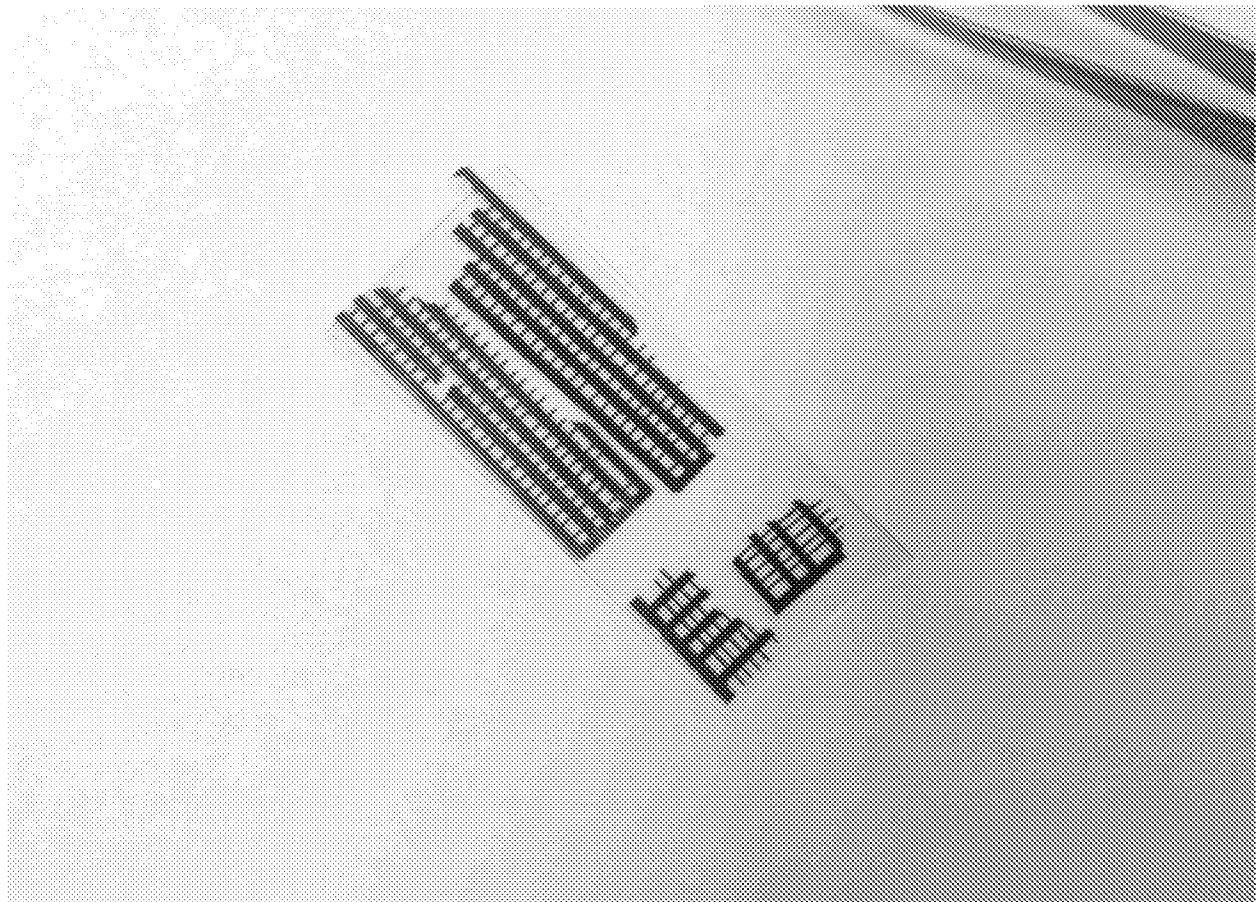


FIG. 3

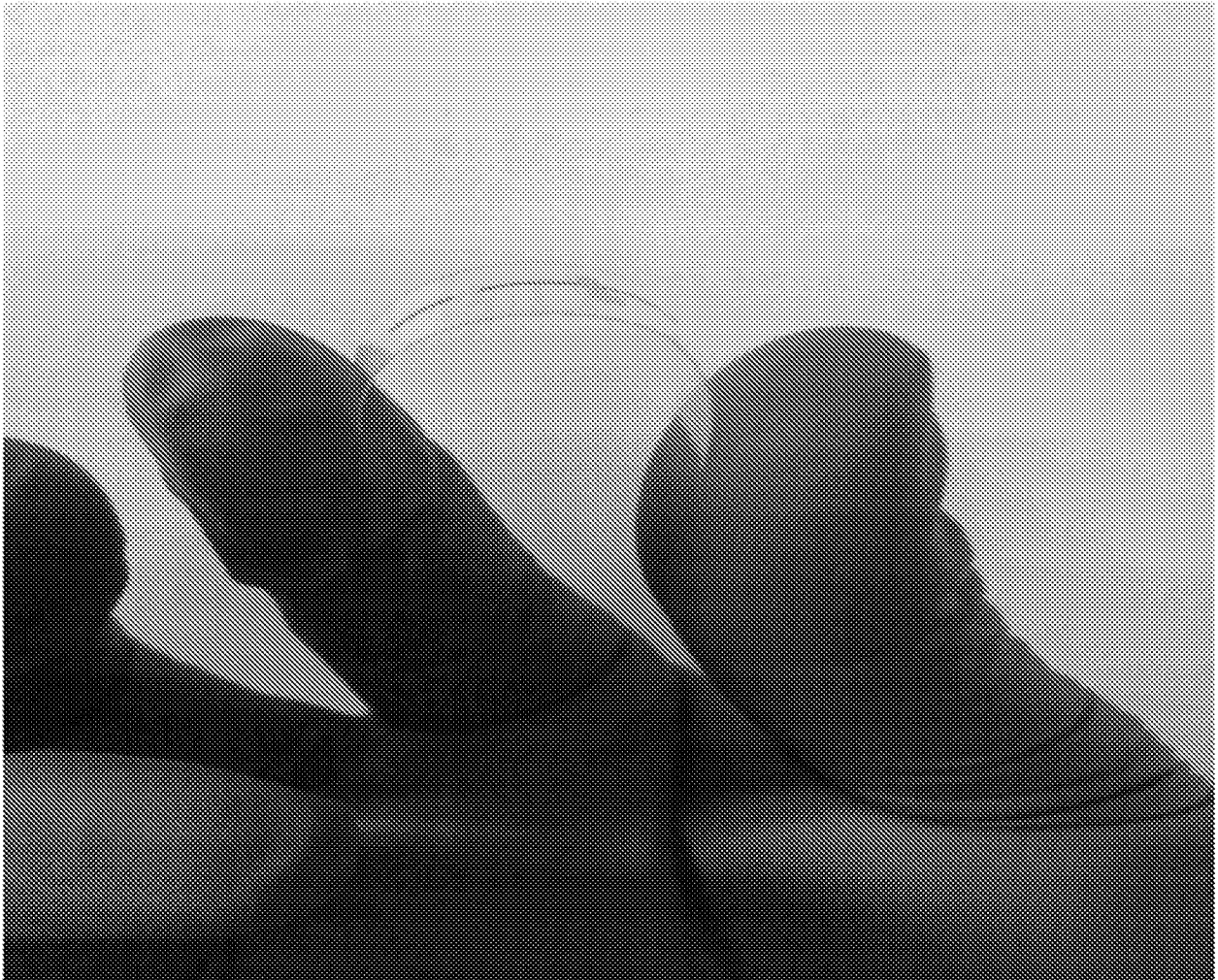


FIG. 4

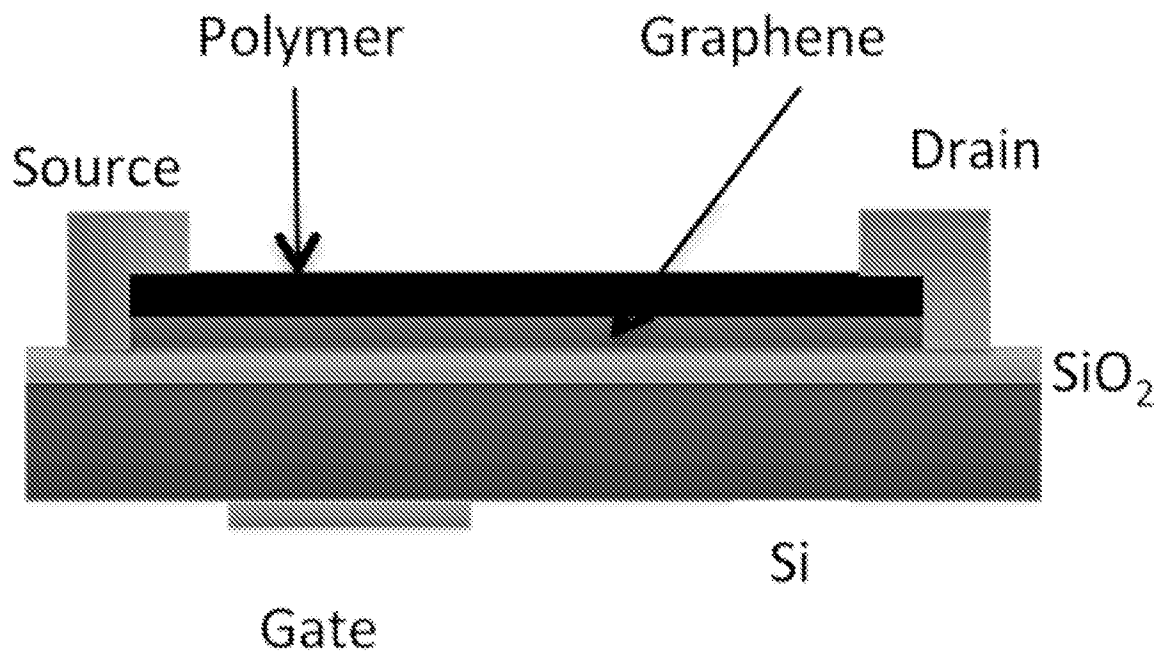
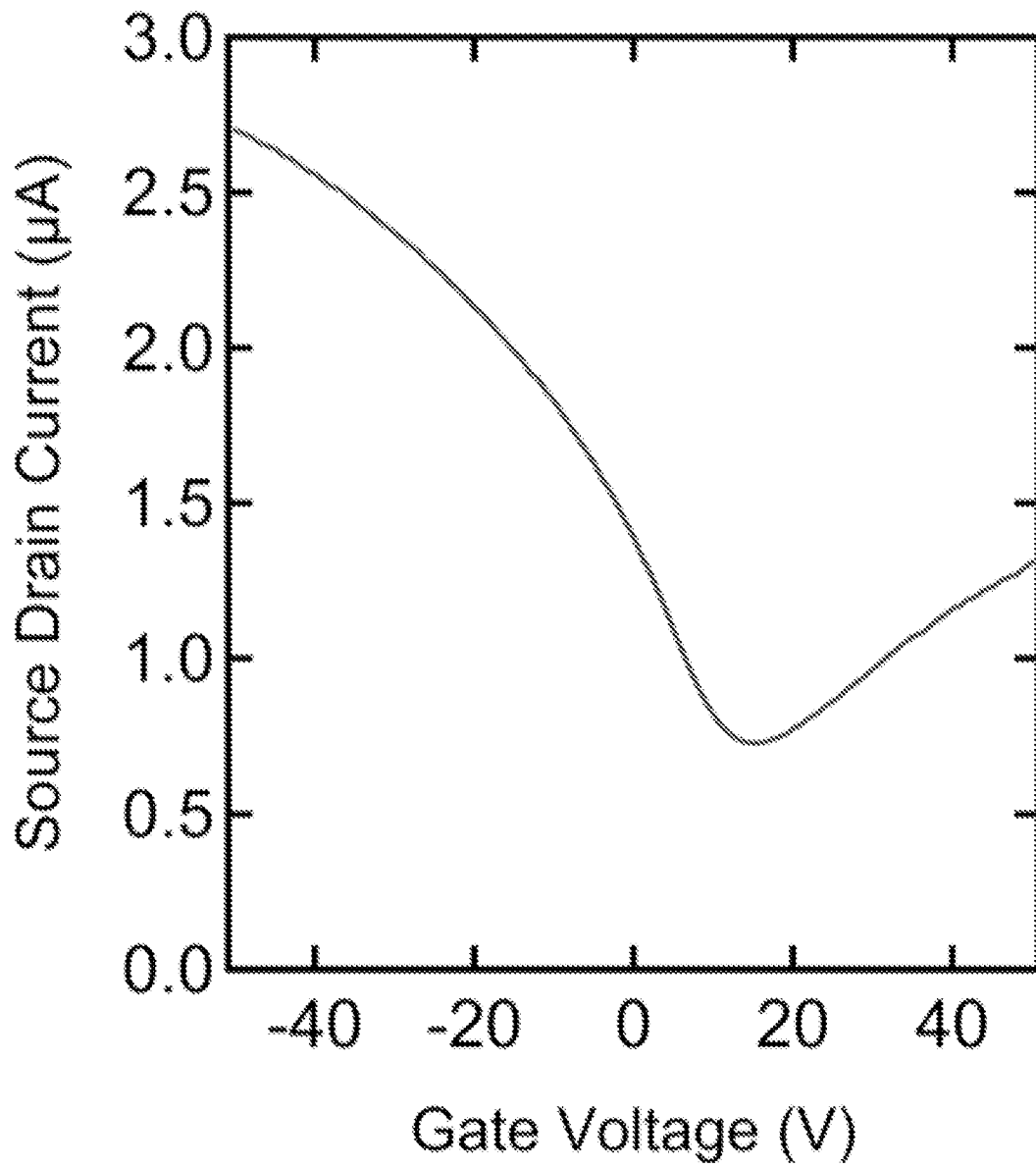


Figure 5(a)

**FIG. 5(b)**

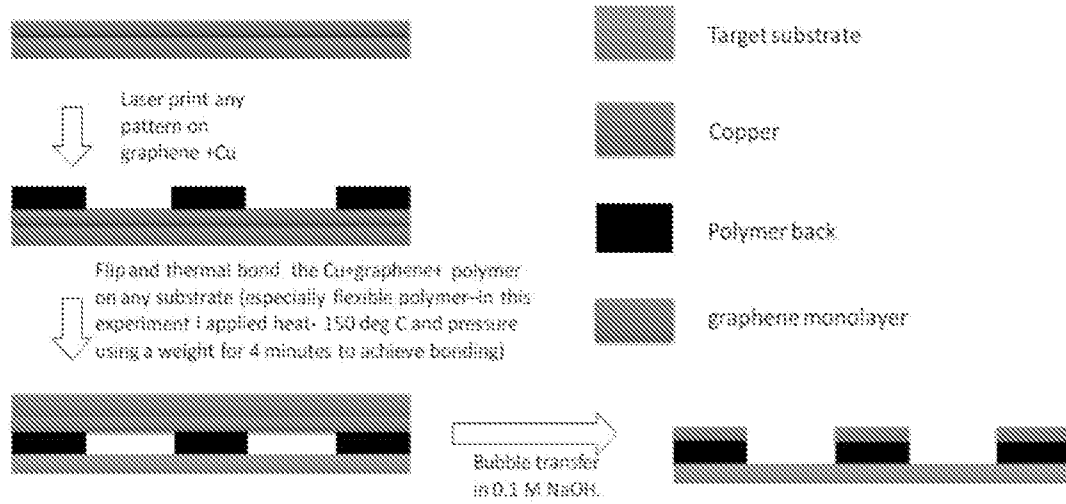


FIG. 6

INTERNATIONAL SEARCH REPORT

International application No.

PCT/US15/27193

A. CLASSIFICATION OF SUBJECT MATTER IPC(8) - B05D 5/12; H05K 3/12 (2015.01) CPC - B05D 5/12; H05K 3/12 According to International Patent Classification (IPC) or to both national classification and IPC		
B. FIELDS SEARCHED Minimum documentation searched (classification system followed by classification symbols) IPC(8): B05D 5/12; H05K 3/10, 3/12 (2015.01) CPC: B05D 5/12; H05K 3/10, 3/12; 3/1216, 3/1241, 3/1275, 3/1283 Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Electronic data base consulted during the international search (name of data base and, where practicable, search terms used) PatSeer (US Granted, US Applications, EP-A, EP-B, WO, JP, DE-G, DE-A, DE-T, DE-U, GB-A, FR-A); Google; Google Scholar; ProQuest; IEEE.com; Keywords Used: graphene, printing, transfer, pattern, mask, exfoliate, bubble, catalyst, nanoimprint		
C. DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 2013/0098540 A1 (SAMSUNG ELECTRONICS CO., LTD.) April 25, 2013; figure 4A; paragraphs [0057, 0064, 0070-0072, 0074, 0078, 0080, 0084].	20-24, 26-28
Y		25
Y	MEITL, M et al., "Transfer printing by kinetic control of adhesion to an elastomeric stamp", December 11, 2005, Nature Materials, Vol. 5, January 2006, [online], [retrieved on 2015-07-09]. Retrieved from the Internet: <URL: http://rogers.matse.illinois.edu/files/2006/nmat1532.pdf>; page 34, figure 2c; page 35, paragraph 3, figures 3b-3d.	25
A	LI, X et al., "Evolution of Graphene Growth on Ni and Cu by Carbon Isotope Labeling", August 27, 2009, Nano Letters (2009) 9, 4268-4272, [online], [retrieved on 2015-07-09]. Retrieved from the Internet: <URL: >; page 4268, abstract, figure 2, paragraph 4; page 4271, paragraph 5.	1-13
A	CHEN, X et al., "The selective transfer of patterned graphene", November 14, 2013, Scientific Reports, 3, 3216, DOI: 10.1038/srep03216, [online], [retrieved on 2015-07-08]. Retrieved from the Internet: <URL: http://www.nature.com/srep/2013/131114/srep03216/pdf/srep03216.pdf>; page 2, paragraph 2, figure 1.	1-13
<input checked="" type="checkbox"/> Further documents are listed in the continuation of Box C. <input type="checkbox"/> See patent family annex.		
* Special categories of cited documents: "A" document defining the general state of the art which is not considered to be of particular relevance "E" earlier application or patent but published on or after the international filing date "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "O" document referring to an oral disclosure, use, exhibition or other means "P" document published prior to the international filing date but later than the priority date claimed "T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art "&" document member of the same patent family		
Date of the actual completion of the international search 10 July 2015 (10.07.2015)		Date of mailing of the international search report 28 JUL 2015
Name and mailing address of the ISA/ Mail Stop PCT, Attn: ISA/US, Commissioner for Patents P.O. Box 1450, Alexandria, Virginia 22313-1450 Facsimile No. 571-273-8300		Authorized officer Shane Thomas PCT Helpdesk: 571-272-4300 PCT OSP: 571-272-7774

INTERNATIONAL SEARCH REPORT

International application No.

PCT/US15/27193

C (Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	KIM, K et al., "Large-scale pattern growth of graphene films for stretchable transparent electrodes", 5 February 2009, Nature, Vol. 457, 706-710, doi:10.1038/nature07719, [online], [retrieved on 2015-07-09]. Retrieved from the Internet: <URL: http://www.physics.purdue.edu/quantum/files/CarbonNano/nature07719.pdf >; page 706, paragraph 2; page 707, figures 1a-1b; page 708, paragraphs 1-2.	1-13
A	LIANG, X et al., "Graphene Transistors Fabricated via Transfer-Printing In Device Active-Areas on Large Wafer", Nano Letters (2007) 7, 3840-3844, November 14, 2007. [online], [retrieved on 2015-07-09]. Retrieved from the Internet: <URL: http://www.bioee.ee.columbia.edu/courses/upload/Bibliography/liang_nanoletters_2007.pdf >; page 3840, figure 1, paragraphs 2-3; page 3841, paragraphs 2-3.	1-13

INTERNATIONAL SEARCH REPORT

International application No.

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Box No. II Observations where certain claims were found unsearchable (Continuation of item 2 of first sheet)

This international search report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:

1. Claims Nos.:
because they relate to subject matter not required to be searched by this Authority, namely:

2. Claims Nos.:
because they relate to parts of the international application that do not comply with the prescribed requirements to such an extent that no meaningful international search can be carried out, specifically:

3. Claims Nos.: 14-19
because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).

Box No. III Observations where unity of invention is lacking (Continuation of item 3 of first sheet)

This International Searching Authority found multiple inventions in this international application, as follows:

1. As all required additional search fees were timely paid by the applicant, this international search report covers all searchable claims.
2. As all searchable claims could be searched without effort justifying additional fees, this Authority did not invite payment of additional fees.
3. As only some of the required additional search fees were timely paid by the applicant, this international search report covers only those claims for which fees were paid, specifically claims Nos.:

4. No required additional search fees were timely paid by the applicant. Consequently, this international search report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:

Remark on Protest

- The additional search fees were accompanied by the applicant's protest and, where applicable, the payment of a protest fee.
- The additional search fees were accompanied by the applicant's protest but the applicable protest fee was not paid within the time limit specified in the invitation.
- No protest accompanied the payment of additional search fees.